



Fully Automatic Dry Etcher **DFE8040/8060**

Realizes distinct dimensional die strength based on the side-etching effect



Stress relief using dry etching

The DFE8040/8060 is a stress relief machine that uses dry etching based on fluoride gas plasma. By removing the grinding damage layer from the wafer backside, there is a decline in wafer breakage, improvement in die strength and reduction in warpage. As a result, it improves the production yield in the packaging process. In addition, because it is a complete dry process, chemical penetration or contamination does not occur. Also, since it is a no-load process, dry etching is suitable for fragile devices.

In combination with the DBG process, there is a further die strength improvement

If the DBG process is combined with the dry etching, in addition to removing the grinding damage layer from the wafer backside, removal of the cutting damage from dicing is also achieved due to side-etching effect. Compared to the stress relief of just the wafer backside, DBG processing with dry etching secures greater die strength.





ISO 9001 REGISTERED ORGANIZATION No. E892 - ISO 14001



DFG8560



Improve product yield with the in-line system

This is premised on the in-line specification of Disco's grinders DFG8560/DFG8540 and DGP8760. In addition, the in-line specification can also support the multifunction wafer mounter DFM2700.

Able to process rough surfaces to improve the adhesion of backside electrode

By conditioning the process surface before etching, it is possible to roughen the plane roughness while it is clean. As a result of this, adhesion improvement of the metallization layer and reduction of Ohm resistance* can be expected for backside electrode formation

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Safe Design

The dry etcher uses innocuous SF₆ gas. The harmful gas that is produced in very small quantities is removed by gas filter. In the inherently dangerous parts of the machine, interlocks are used to ensure safety. Also, the machine structure conforms to EU machine protocols and EMC protocols.





DFE8060

*Ohm Resistance: Is the sum of the contact resistance between materials and material specific resistance. Reduction of Ohm Resistance is important in the case of power MOS and other devices. The lower the resistance, the more ability there is to control the power loss at the time of device operation. Also, a higher current can pass through the device

DFE8040/8060 Specifications

			DFE8040	DFE8060	
Wafer Diameter			ø8"	ø8" or ø12"	
Processing Method			High-density, high-pressure, narrow-gap plasma		
Treatmen	t gas used		SF6/He/N2		
Wafer	No. of cassettes	2			
transport section	Cassette section wafer	flow Open flow (Storage only)			
	Transfer arm	Transports wafers from the spinner table of the grinder to the chuck table in the chamber Transports etched wafers from the chuck table in the chamber to the dummy table.			
	Dummy table	Table onto which etched wafers are transported by the transfer arm before they are unloaded into the cassette by the robot.			
	Robot	Transports etched wafers from the dummy table to the cassette.			
	Cassette stage	Plate on which a cassette to store etched wafers is placed.			
	Cassette used		DBG cas	sette only	
Utility Uni	it Dry-pump		Used to exhaust the chamb	Der. *The recommended overhaul	
	Exhaust velocity	m³/h	2	27	
	Ultimate pressure	Pa	10	abs	
	Rotary pump		Used to vacuum the chuck	< table. The recommended overhau	
	Exhaust velocity	m³/h	1	.9	
	Ultimate pressure	Pa	0.3	abs	
	RF power		High-frequency power us	sed for plasma generation	
	Mass flow controller	Begulates supply gas flow.			
	Valves	Used for etching section/utility gas section operation control			
	Gas detector	Detects HE leakage from the machine/utility unit			
		* It is recommended that the break monitor is calibrated once in half a year.			
	Gas filter	E	liminates such substances as HF, SiF4, ar	nd SOF2 from residual gas after etching	
Coolant U	Jnit (2: one for co	oling th	the upper electrode and the other * The below specifications sh	for cooling the lower electrode now the values for one unit.	
	Temperature set up ran	ge∘c	+5 ~	- +35	
	Max. flow	L/min	15	12	
	Max. pumping pressure	MPa	0.	.42	
	Cooling capacity	kW	2.41 (water temperature set at 20°C) 3.5 (water temperature set at 20°C	
	Water used		Deioniz	ed water	
Utilities	Electricity				
	Power supply	200 ~ 240 V AC±10 %, 3-phase (50/60 Hz) For other than the above voltages, a transformer is necessary			
	Power consumption	ר kW	5.0 (during plasma generation) 3.4 (during standby)	7.0 (during plasma generation) 4.0 (during standby)	
		*The abo	ve values are reference values. They may va	ary depending on the operating conditions	
	Maximum power	kVA	17	25	
	Treatment Gas				
	Gas used	5	SF6 : 99.99% or higher in purity,	He : 99.99% or higher in purity	
	Pressure reducer	Mpa	0.1 Variation: 0.03 at Max	*The pressure regulator and the gas filte should be furnished by the user.	
	Purge Gas				
	Gas used		N2		
	Supply pressure	MPa	Range: 0.5 to 0.8, Variation: 0.03		
	For chamber				
	Flow rate	L/min	min 50 or higher		
	Consumption per w	afor I	for 1 6 "Provided that the purge time is 7 sec. and the		



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For dry pump Flow rate 1.5 L/min 1.5 *Provided that wafer processing time per wafer is 60 se Consumption per wafer Range: 0.5 ~ 0.8, Variation: 0.03 Max. Air Supply pressure MPa Flow rate 400 or higher Water Water used for cooling electrodes Coolant water (Coolant unit) 10 ~ 15 (Total of two coolant units) ircularly used. Supply deionized water as needed Air Exhaust Machine main body exhaust system: Detect gas leakage inside the machine. his system prevents harmful gases from leaking outside of the achine when abnormality occurs in the machine or the process. Function *This system prevents harn machine when abnormality the west excitation of the pictures
 4 or higher
 he exhaust duct hose conflection port of the machine
 hody when static pressure is as below mentioned.
 - 1200 to -130 (at the exhaust duct hose connection
 of the machine main body Exhaust capacity m3/min Static pressure Pa ort of the ma Utility unit exhaust system: Detect gas leakage inside the utility unit and exhaust heat. Function 7 or higher (at the exhaust duct main body when st Exhaust capacity m3/min Static pressure Pa Process gas exhaust system: Function Exhaust gases after processing his system expels gases generated in the etching ass through the gas filter. Unused SF6 is include after they Exhaust capacity m3/min 0.6 or higher -1,200 ~ -45 (at the exhaust duct hose of port of the machine main b Static pressure Pa Machine Dimensions (W × D × H) 1,400 x 2,500 x 1,800 (excluding the status indicato (324 mm) and other protrusions) 775 x 942 x 1,525 Main body Utility unit Coolant unit (2) 413 x 610 x 664 (per unit) 540 x 743 x 772 (per unit) Machine Weight About 870 Main body kg About 1,048 About 230 (excluding the gas filter of about 40 kg) Utility unit kg Coolant unit (2) About 130 x 2 About 90 x 2

DFE8040

Environmental conditions

Use clean, oil-free air at a dew point of -15 °C or less. (Use a residual oil: 0.1 ppm. Filtration rating: 0.01 μm/99.5 % or more).

Keep room temperature fluctuations within ±1 °C of the set value. (Set value should be between 20 – 25 °C).
The machines should be used in an environment, free from external vibration. Do not install machine near a ventilation opening, heat generation equipment or oil mist generating parts.
Be sure to use compressed air as the main air and sub air sources.

Residual gas exhausted from the machine after etching contains such toxic substances as HF, SIF4, SOF2 and SF6. Follow the environmental protection codes of the area the machine is installed for control/disposal of such substances.

 In case of water leakage, please install the machine on the floor with sufficient waterproofing and drainage treatments. Please install a gas leakage detector at the plant (at the customer side) as well.

You must wear a gas mask when performing maintenance work. Make sure to have one ready
 Please prepare emergency plans to deal with accidents.

All pressures specified above are gauge pressures.
 As the above specification may change due to technical modifications. Please confirm when placing your order.
 For further information, please contact your local sales representative.

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